

ICPST-42 (2025) Time Table

Tuesday, June 24, 2025

	Medium Hall	
13:00	Tutorial 13:00-18:00	
13:30		
14:00		
14:30		
15:00		
15:30		
16:00		
16:30		
17:00		
17:30		
18:00	Welcome Reception 18:00-20:00	
18:30		
19:00		
19:30		
20:00		

Wednesday, June 25, 2025

	Medium Hall	Small Hall	Room 408	Room 409
9:30	Opening Remarks 9:30-9:45			
9:45	SPST Award Ceremony 9:45-10:00			
10:00				
10:30	A0. Plenary Talks 10:00-11:30			
11:00				
11:30	Lunch			
12:00				
12:30				
13:00	A3. Directed Self Assembly (DSA) 13:00-17:30	A2. Nanobio technology 13:00-17:30	A6. Nanoimprint 12:50-16:30	A12. Fundamentals and Applications of Biomimetics Materials and Processes
13:30				
14:00				
14:30				
15:00			A8. Photopolym. in 3-D Printing/ Additive Manufacturing 16:30-17:40	
15:30				
16:00				
16:30				
17:00				
17:30	Coffee Break with snacks			
18:00	Panel Discussion 18:00-20:00			
18:30				
19:00				
19:30				
20:00				

Thursday, June 26, 2025

	Medium Hall	Small Hall	Room 408	Room 409	
9:00	A5. EUV Lithography 9:00-11:30	A9. Strategies and Materials for Advanced Packaging, Next Generation MEMS, Flexible Devices 9:00-16:40	B2. Plasma Photochemistry and Functional- ization of Polymer Surfaces (Japanese symposium) 9:30-12:00		
9:30					
9:45					
10:00			B3-5. General Scopes of Photopolymer Science and Technology (Japanese Symposium) 10:00-12:15		
10:30					
11:00					
11:30	A4. Computational / Analytical Approach for Lithography Processes 11:30-16:00				
12:00					
12:30					Lunch
13:00					A13. + B1. Polyimides and High Thermally Stable Resins - Functionalization and Practical Applications 13:00-16:30
13:30					
14:00					
14:30					
15:00					
15:30					
16:00					
16:30					
17:00					
17:30	Banquet at Hotel Monterey Himeji 17:30-20:00				
18:00					
18:30					
19:00					
19:30					
20:00					

Friday, June 27, 2025

	Medium Hall	Small Hall	Room 408	Room 409
9:00	A5. EUV Lithography 9:00-16:40		A11. Organic and Hybrid Materials for Photovoltaic and Optoelectronic Devices 9:00-16:45	B3. General Scopes of Photopolymer Science and Technology (Japanese Symposium) 9:00-11:00
9:30				A10. Chemistry for Advanced Photopolymer Science 13:00-16:05
9:45				
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16:00				
16:30	Closing Remarks 16:45-16:55			
17:00				